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(54)	METHOD OF FABRICATING SIO ₂ SPACERS					
AND ANNEALING CAPS						

(75) Inventors: Sadanand V. Deshpande, Fishkill, NY

(US); Bruce B. Doris, Brewster, NY (US); Rajarao Jammy, Wappingers Falls, NY (US); William H. Ma,

Fishkill, NY (US)

Assignee: International Business Machines

Corporation, Armonk, NY (US)

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Int. Cl.⁷ H01L 29/76 (51)

U.S. Cl. **257/333**; 257/346; 257/387; (52)257/340; 257/412; 257/388; 438/585

(58)257/387, 388, 340, 900, 412; 438/585

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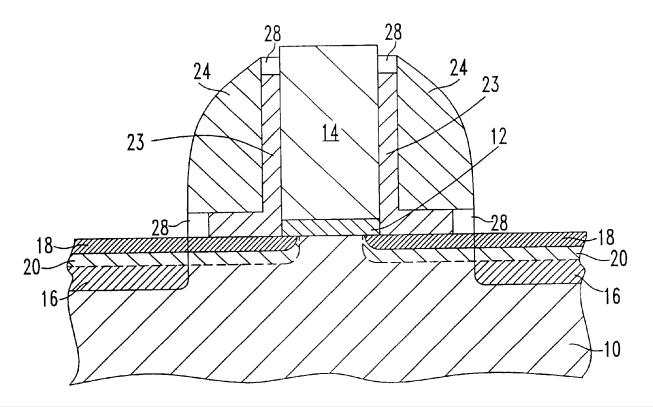
Primary Examiner—Nathan J. Flynn Assistant Examiner—Scott R. Wilson

(74) Attorney, Agent, or Firm-Margaret A. Pepper

ABSTRACT (57)

Divot fill methods of incorporating thin SiO₂ spacer and/or annealing caps into a complementary metal oxide semiconductor (CMOS) processing flow are provided. In accordance with the present invention, the divot fill processes provide a means for protecting the exposed surfaces of the thin SiO₂ spacer and/or annealing cap such that those surfaces are not capable of being attacked by a subsequent silicide precleaning step. CMOS devices including thin SiO2 spacer and/or annealing caps whose surfaces are protected such that those surfaces are not capable of being attacked by a subsequent silicide pre-cleaning or other process steps are also provided.

24 Claims, 7 Drawing Sheets





^{*} cited by examiner

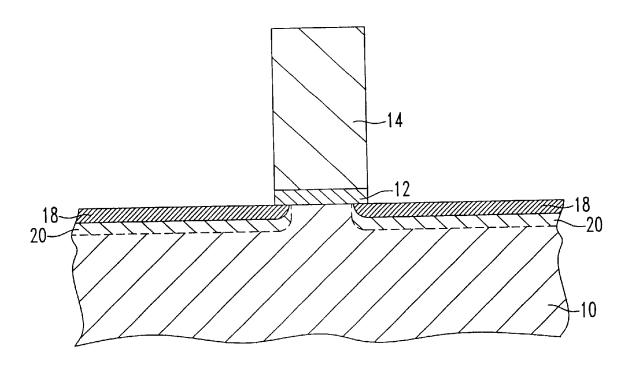


FIG. 1A

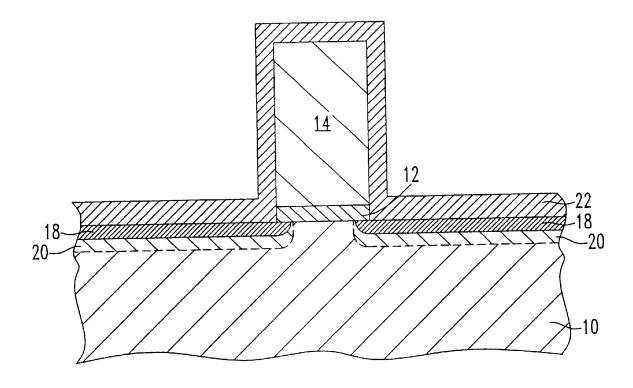


FIG. 1B



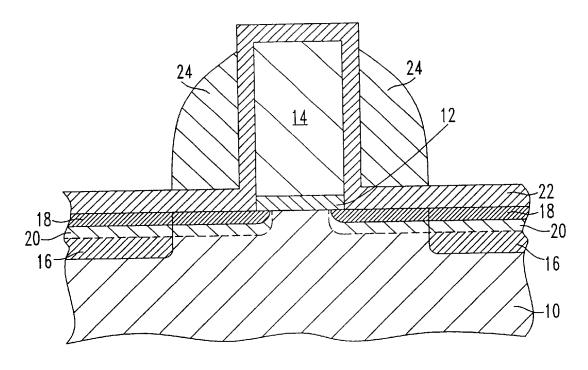


FIG. 1C

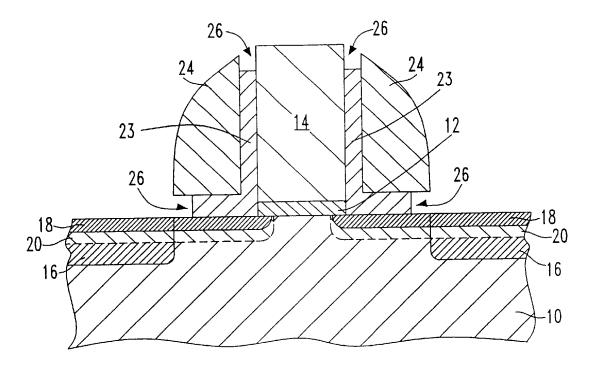


FIG. 1D



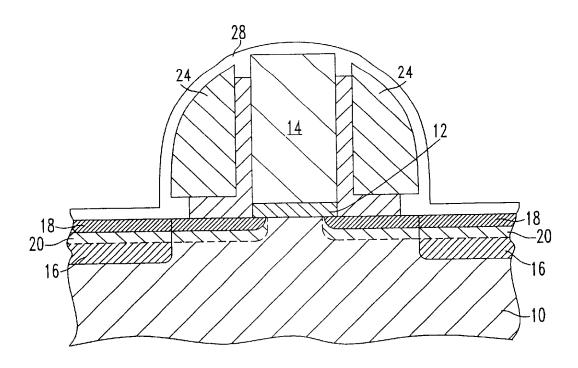


FIG. 1E

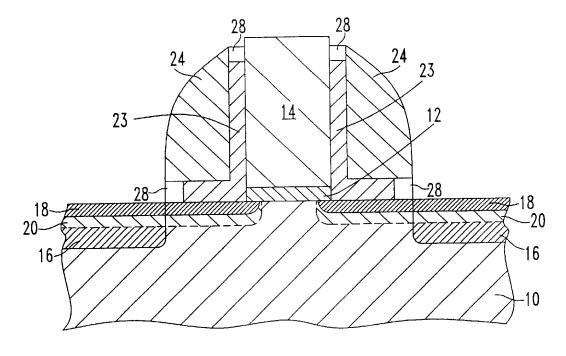


FIG. 1F



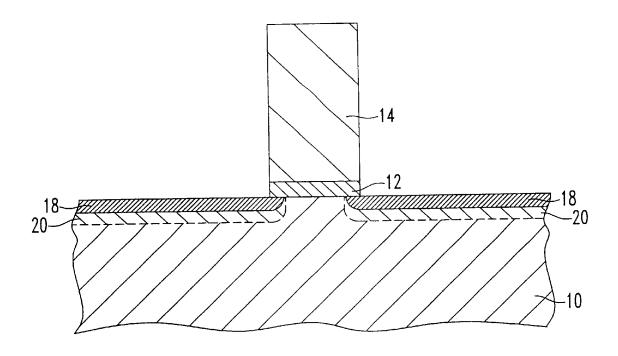


FIG. 2A

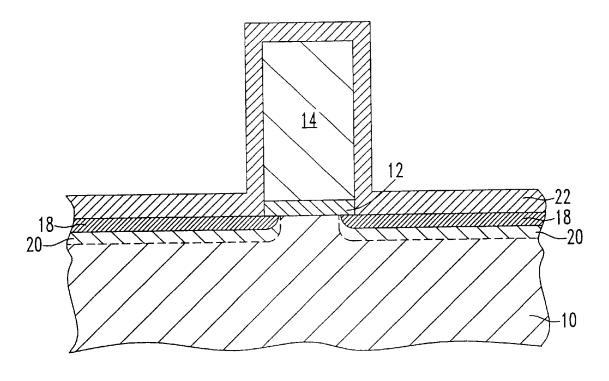


FIG. 2B



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